METHOD 2002.4

MECHANICAL SHOCK

1. PURPOSE. The shock test is intended to determine the suitability of the devices for use in electronic equipment which may be subjected to moderately severe shocks as a result of suddenly applied forces or abrupt changes in motion produced by rough handling, transportation, or field operation. Shocks of this type may disturb operating characteristics or cause damage similar to that resulting from excessive vibration, particularly if the shock pulses are repetitive.

2. APPARATUS. The shock-testing apparatus shall be capable of providing shock pulses of 500 to 30,000 g (peak) as specified with a pulse duration between 0.1 and 1.0 millisecond, to the body of the device. The acceleration pulse shall be a half-sine waveform with an allowable distortion not greater than ±20 percent of the specified peak acceleration, and shall be measured by a transducer and optional electronic filter with a cut-off frequency of at least 5 times the fundamental frequency of the shock pulse. The pulse duration shall be measured between the points at 10 percent of the peak acceleration during rise time and at 10 percent of the peak acceleration during decay time. Absolute tolerances of the pulse duration shall be the greater of ±0.1 millisecond or ±30 percent of the specified duration.

3. PROCEDURE. The shock-testing apparatus shall be mounted on a sturdy laboratory table or equivalent base and leveled before use. The device shall be rigidly mounted or restrained by its case with suitable protection for the leads. Means may be provided to prevent the shock from being repeated due to "bounce" in the apparatus. Unless otherwise specified, the device shall be subject to 5 shock pulses of the peak (g) level specified in the selected test condition and for the pulse duration specified in each of the orientations X_1, X_2, Y_2, Y_1, Z_1, and Z_2. For devices with internal elements mounted with the major plane perpendicular to the Y axis, the Y_1 orientation shall be defined as that one in which the element tends to be removed from its mount. Unless otherwise specified, test condition B shall apply.

Test condition	g level (peak)	Duration of pulse (ms)
A	500	1.0
B	1,500	0.5
C	3,000	0.3
D	5,000	0.3
E	10,000	0.2
F	20,000	0.2
G	30,000	0.12

CAUTIION: If this test is performed using a potting compound type test fixture (e.g., waterglass/sodium silicate) the facility performing the test shall assure that this procedure/material does not mask fine/gross leakers.

3.1 Examination. After completion of the test, an external visual examination of the marking shall be performed without magnification or with a viewer having a magnification no greater than 3X and a visual examination of the case, leads, or seals shall be performed at a magnification between 10X and 20X. This examination and any additional specified measurements and examination shall be made after completion of the final cycle or upon completion of a group, sequence, or subgroup of tests which include this test.

3.2 Failure criteria. After subjection to the test, failure of any specified measurements or examination (see 3 and 4), evidence of defects or damage to the case, leads, or seals, or illegible markings shall be considered a failure. Damage to marking caused by fixturing or handling during tests shall not be cause for device rejection.

4. SUMMARY. The following details shall be specified in the applicable acquisition document:

a. Test condition, if other than test condition B (see 3).

b. Number and direction of shock pulses, if other than specified (see 3).

c. Electrical-load conditions, if applicable (see 3).

d. When required, measurement made after test (see 3 and 3.1).

e. When required, measurement during test.